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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Hung et al.

Docket: 3245

Serial No. 09/276,376

Group No. 1763

Filed: March 25, 1999

Examiner:

For: ENHANCEMENT OF SILICON OXIDE ETCH RATE AND SUBSTRATE
SELECTIVITY AND XENON ADDITION

Assistant Commissioner for Patents
Attn: Office of Initial Patent Examination
Customer Service Center
Washington, DC 20231

REQUEST FOR CORRECTED FILING RECEIPT

Attached is a copy of the official Filing Receipt received from the U.S. Patent and Trademark Office in the above-referenced patent application, for which issuance of a corrected Filing Receipt is respectfully requested.

The errors to be corrected are as follows:

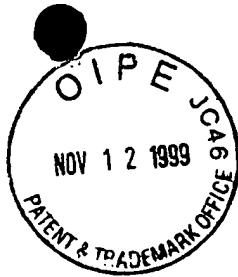
1. Correct the first name of the third inventor from HONGCHIN to HONGQING
2. Change the Mailing Address to:

Patent Counsel, MS/2061
Legal Affairs Dept.
Applied Materials, Inc.
P.O. Box 450A
Santa Clara, CA 95052

The correction is required due to Patent Office error, and no fee is believed to be necessary.

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The Commissioner is authorized to charge to Deposit Account No. 01-1651 any fees required to correct any errors in nonpayment or improper payment of a required fee.

Date: Nov. 10, 1999

Respectfully submitted

Charles S. Guenzer, Reg. No. 30,640

Attorney for Applicants

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Palo Alto, CA 94306

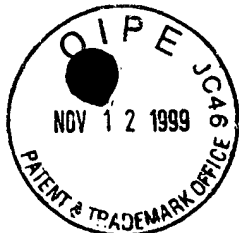
I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below, with sufficient postage as first-class mail, in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, DC 20231.

Date: 11/10/99

C. Guenzer

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FILING RECEIPT
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UNITED STATES DEPARTMENT OF COMMERCE
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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTORNEY DOCKET NO.	DRWGS	TOT CL	IND CL
09/276,376	03/25/99	1763	\$890.00	AM-3245	5	20	2

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Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts of Application" ("Missing Parts Notice") in this application, please submit any corrections to this Filing Receipt with your reply to the "Missing Parts Notice." When the PTO processes the reply to the "Missing Parts Notice," the PTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s) HOIMAN(RAYMOND) HUNG, SAN JOSE, CA; JOSEPH P. CAULFIELD, OAKLAND, CA; ~~HONGCHIN SHAN~~, CUPERTINO, CA; MICHAEL RICE, PLEASANTON, CA; KENNETH S. COLLINS, SAN JOSE, CA; CHUNSHI CUI, SANTA CLARA, CA.

HONGQING

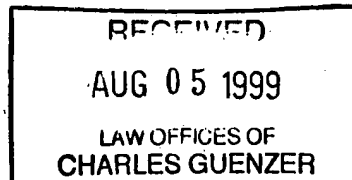
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TITLE

ENHANCEMENT OF SILICON OXIDE ETCH RATE AND SUBSTRATE SELECTIVITY WITH XENON ADDITION

PRELIMINARY CLASS: 216

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DATA ENTRY BY: SCOTT, JOSEPH

TEAM: 03 DATE: 07/29/99

(See reverse for new important information)

Docketed 8-7-99